



PATENT

Case Docket No. ASMNUT.029CP1

Date: November 17, 2004

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s) : Basol et al.
Appl. No. : 10/822,424
Filed : April 12, 2004
For : SYSTEM FOR
ELECTROPOLISHING AND
ELECTROCHEMICAL
MECHANICAL POLISHING
Examiner : Unknown
Group Art Unit : 1742

I hereby certify that this correspondence and all marked attachments are being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, Mail Stop Amendment, P.O. Box 1450, Alexandria, VA 22313-1450, on

November 17, 2004

(Date)

Tina Chen, Reg. No. 44,606


TRANSMITTAL LETTER

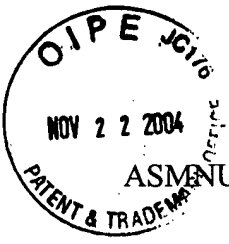
Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application are:

- (X) A Preliminary Amendment in 4 pages.
- (X) The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment, to Account No. 11-1410.
- (X) Return prepaid postcard.


Tina Chen
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CERTIFICATE OF MAILING

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PRELIMINARY AMENDMENT

Mail Stop Amendment

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

Prior to examination on the merits in the above-referenced application, please amend the application as indicated below.

Amendments to the Specification begin on page 2 of this paper.

Remarks/Arguments begin on page 3 of this paper.